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## 1. Introduction

In recent years, degradation of organic compounds by photocatalysis has become a very attractive research subject in the field of environmental pollution treatment. Different metal oxide semiconductors have been studied. Among various metal oxide photocatalysts,  $TiO_2$  is indicated to be an ideal photocatalyst with great application prospects because of its strong catalytic activity and high chemical stability.<sup>1-3</sup> However, there are still some problems to be solved in practical applications, such as the low utilization of light and the recombination of photogenerated electron-hole pairs. In order to improve its photocatalytic performance, many methods have been proposed, such as metal ion doping,<sup>4,5</sup> nonmetal ion doping,<sup>6,7</sup> noble metal deposition,<sup>8</sup> oxide semiconductor coupling,<sup>9,10</sup> surface sensitization,<sup>11</sup> etc.

Theoretical and experimental studies demonstrate that nonmetal ion doping is one of the most common and effective methods to improve the photocatalytic performance of  $TiO_2$ . Compared with other methods, non-metal doping is a kind of modification method with economic benefits. Irie *et al.*<sup>12</sup> fabricated the carbon-doped  $TiO_2$  powders with red-shift

# Preparation of high-concentration substitutional carbon-doped TiO<sub>2</sub> film *via* a two-step method for high-performance photocatalysis

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In this paper, we present a facile two-step method for preparing a high-concentration substitutional carbon-doped TiO<sub>2</sub> (TiO<sub>2-x</sub>C<sub>x</sub>) film. First, the titanium substrate undergoes gas carburizing, followed by micro-arc oxidation (MAO) to form a carbon-doped TiO<sub>2</sub> film on the surface. The process can be described as direct oxidation of titanium carbide ( $O \rightarrow TiC_x$ ). The experimental results reveal that compared with traditional thermal annealing, this process could increase the carbon doping concentration to 6.07 at% and x to 0.24 in TiO<sub>2-x</sub>C<sub>x</sub>. The TiO<sub>2-x</sub>C<sub>x</sub> film exhibits a significant red-shift in the band-gap transition, a narrow band gap of 2.77 eV, and excellent photocatalytic performance, more than two times higher than that of undoped TiO<sub>2</sub> film. This method is simple, efficient, economical, environmentally friendly, and adapts to mass production. This experimental strategy can also be used in preparing other doped elements.

adsorption spectra through direct thermal oxidation of TiC. It was found that carbon atoms were located at oxygen sites and formed the Ti-C bonds, but the carbon doping concentration in TiO<sub>2</sub> was very low, only 0.32%. Park et al.<sup>13</sup> obtained the  $TiO_{2-x}C_x$  nanotube array by controlling the anodizing conditions, favoring the incorporation of carbon by heating with CO at temperatures up to 600 °C. The total photocurrent of the  $TiO_{2-x}C_x$  nanotube array was more than 20 times higher than that of regular P-25. Wu et al.14 synthesized the carbon-doped TiO<sub>2</sub> micro-/nanospheres and nanotubes via single-source chemical vapor deposition in an inert atmosphere. The estimated optical band gap was 2.78 eV for the carbon-doped TiO<sub>2</sub> microspheres and 2.72 eV for the carbon-doped TiO<sub>2</sub> nanotubes, both of which were much smaller than that of bulk anatase TiO<sub>2</sub> (3.20 eV). Dong et al.<sup>15</sup> prepared carbon-doped TiO<sub>2</sub> with high visible light activity using a green synthetic approach with glucose as carbon doping source. It was found that the visible light absorbance of the thermally treated sample could be broadened due to the increased content of doped carbon. Wu et al.<sup>16</sup> prepared carbon-doped TiO<sub>2</sub> powders by a facile calcination-assisted solvothermal method. The experimental results showed that the carbon-doped TiO<sub>2</sub> samples exhibited not only a very good ability to destroy NO gas, but also an excellent ability to degrade methyl orange solution under visible light, much superior to P25 and N-TiO2. Rasoulnezhad et al.17 synthesized carbon-doped TiO2 thin films on glass substrate by a combination of chemical vapor deposition and ultrasonic methods. It was found that carbon doping in the TiO2 structure greatly improved the optical properties for visible light absorption.



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In general, the doping content of nonmetal-doped TiO<sub>2</sub> films produced using the regular doping method is low, found mostly as interstitial doping, and has poor thermal stability. In our previous work, various TiO<sub>2</sub> composite films, such as TiO<sub>2</sub>/ YAG:Ce<sup>3+</sup> and TiO<sub>2</sub>/Eu<sub>2</sub>O<sub>3</sub> composites, have been prepared in situ by using micro-arc oxidation (MAO) technique on the titanium or titanium alloy substrate for high photocatalytic performance.18,19 In particular, we reported a new process which combined the technique of plasma nitriding and MAO to simply prepare a high-concentration substitutional N-doped TiO<sub>2</sub> photocatalytic film.<sup>20</sup> The principle is that the rapid oxidation process of MAO can restrict the nitrogen atoms' escape from the substrate and maximally keep the nitrogen atoms in the TiO<sub>2</sub> film. Moreover, due to the direct oxidation reaction of TiN, the Ti-N bond is retained to the maximum extent, and more substitutional N-doped TiO<sub>2</sub> is obtained.

In this paper, a facile two-step method is applied to prepare substitutional carbon-doped  $\text{TiO}_2$  film with high doping content. That is, as an important thermochemical treatment, gas carburizing is firstly used to form a carburized layer with rich TiC compound upon the titanium (Ti) surface, and then MAO treatment is used to directly oxidize the TiC compound into carbon-doped TiO<sub>2</sub> film. Because of the fast, hightemperature, and *in situ* MAO treatment, the resulting carbon doping is of high content and in the form of substitutional doping in the TiO<sub>2</sub> crystal lattice as the TiO<sub>2-x</sub>C<sub>x</sub> film. Compared to plasma nitriding, gas carburizing has the advantages of simpler operation, higher carburizing concentration, large area, and more potential industrial application, among others.

## 2. Experimental

The two-step process for preparing the  $\text{TiO}_{2-x}C_x$  film is as follows: (1) preparation of the  $\text{TiC}_x$  compound on the Ti substrate *via* gas carburizing in a self-made tubular furnace, *i.e.*, the Ti substrate was placed in a quartz tube reactor, heated to 600 °C, kept in 30 sccm C<sub>2</sub>H<sub>2</sub> for 20 h, then kept in closed C<sub>2</sub>H<sub>2</sub> for 10 h, and finally cooled to room temperature, while 200 sccm Ar gas was continuously introduced into the quartz tube. (2) Preparation of the TiO<sub>2-x</sub>C<sub>x</sub> film *via* MAO, *i.e.*, the carburized Ti substrate was used as anode in 5 L electrolyte (Na<sub>3</sub>PO<sub>4</sub>·12H<sub>2</sub>O 10 g L<sup>-1</sup>), and 400 V constant pressure mode was adopted. As a comparison, a pure TiO<sub>2</sub> film was also prepared *via* MAO under the same experimental conditions on the Ti substrate. The detailed experimental conditions are listed in Table 1.

The morphology and chemical compositions of the samples were characterized using a scanning electron microscope (Sirion SEM; FEI, Eindhoven, The Netherlands) with an energydispersive X-ray spectrometer (EDS). The phase analysis proceeded using an X-ray diffraction spectrometer (XRD) (D8 Advanced XRD; Bruker AXS, Karlsruhe, Germany) with Cu K $\alpha$ source. The quantitative elemental compositions were analyzed by X-ray photoelectron spectroscopy (XPS) (VG Multilab 2000, Thermo Scientific, UK). UV-Vis diffuse reflectance spectra (DRS) of the samples were measured by using a diffuse reflectance accessory of the UV-Vis spectrophotometer (UV-2550; Shimadzu, Kyoto, Japan).

The photocatalytic performance was tested according to the following process: a 450 W high-pressure mercury lamp was used as light source, and  $1 \times 1$  cm<sup>2</sup> samples were placed in

Table 1 Experimental conditions of MAO									
		Electrical p	Electrolyte						
		Voltage (V)							
Samples	Anode	Positive	Negative	Frequency (kHz)	Duty cycle (%)	Time (min)	$Na_{3}PO_{4} \cdot 12H_{2}O(g L^{-1})$		
$TiO_2$	Ti	400	0	1	20	3	10		
$TiO_{2-x}C_x$	$TiC_x$	400	0	1	20	3	10		

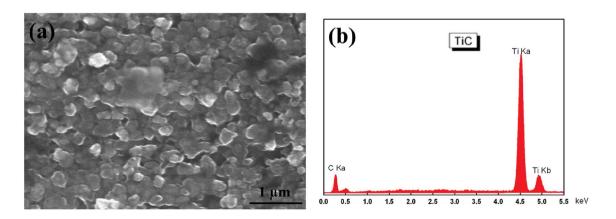


Fig. 1 Surface characteristics of the carburized layer: (a) SEM morphology, (b) EDS profile.

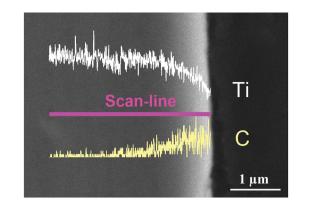


Fig. 2 EDS line-scanning profiles of the carburized layer crosssection.

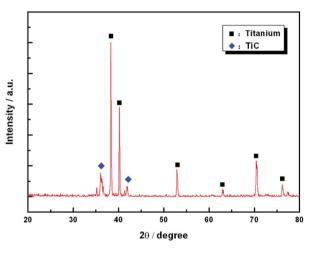


Fig. 3 XRD pattern of the carburized layer.

a quartz colorimetric dish containing 2 mL terephthalic acid (TA) solution (10 mM NaOH and 3 mM  $C_8H_6O_4$ ). Changes in the 2-hydroxy-terephthalic acid (TAOH) concentration were measured by UV-Vis spectrophotometer (UV-2550; Shimadzu) every 60 min.

#### 3. Results and discussion

Fig. 1 shows the SEM morphology and EDS profile of the gas carburized Ti substrate. It could be seen that the surface is

loose, and there are many submicron grain sizes. EDS analysis revealed that besides Ti element, carbon (C) peaks also appeared obviously, which indicated that C atoms were infiltrated into the Ti substrate. From the cross-section of the gas carburized Ti substrate, as shown in Fig. 2, the carburized layer was about 1  $\mu$ m in thickness, and the Ti and C content changed with a opposite variation from the outside surface into the interior substrate. Fig. 3 shows the XRD pattern of the gas carburized Ti substrate; evidently, TiC phase existed in the carburized layer.

Fig. 4 and 5 show the SEM morphologies of pure TiO<sub>2</sub> film and the TiO<sub>2-x</sub>C<sub>x</sub> film after MAO treatment, respectively. Both films showed no obvious difference; that is, all of the mesopores were separated well and distributed homogeneously over the film's surfaces with a diameter around 0.2–1 µm and thickness about 3–4 µm. It could be seen from Fig. 2 that the carburized layer was about 1 µm in thickness after gas carburizing. However, the coating thickness after MAO treatment was about 3–4 µm, which indicated a complete reaction in the carburized layer. Fig. 6 illustrates the XRD patterns of pure TiO<sub>2</sub> film and the TiO<sub>2-x</sub>C<sub>x</sub> film after MAO treatment, respectively. Both films were mainly composed of anatase phase, and no new phase was produced during doping. A small amount of TiC phase in the TiO<sub>2-x</sub>C<sub>x</sub> film indicated that TiC was not completely oxidized to TiO<sub>2-x</sub>C<sub>x</sub> during MAO treatment.

XPS is an effective technique for verifying the concentration of elements on the surface of materials.<sup>21</sup> In order to confirm the carbon atom site and content in the  $TiO_{2-r}C_r$  film, XPS analysis was conducted, as shown in Fig. 7. Besides the element phosphorus (P) from the electrolyte, the existence of C element was clearly observed. In general, the doped C has two existing modes in the  $TiO_2$  lattice: (1) C replaces the position of oxygen (O) to form a O-Ti-C structure; (2) C is stabilized at an interstitial position.22 The multiplex high-resolution scans over the C 1s spectral region revealed two peaks at 284.8 and 282.3 eV, respectively. According to the commonly recognized C-C (285.3 eV) and Ti-C (281.9 eV) bonds,23,24 we believe that these two peaks belong to the C-C and Ti-C bonds, respectively. The C-C peak at 284.8 eV was the C peak for XPS calibration, not the peak of C in the sample, so its content was very high. Only the Ti-C peak at 282.3 eV was the peak of C in the  $TiO_{2-x}C_x$  film. According to these XPS results, the O concentration was about 44.94 at%, compared with 44.10 at% of C. According to the area ratio of the C-C and Ti-C peaks, the concentration of Ti-C could

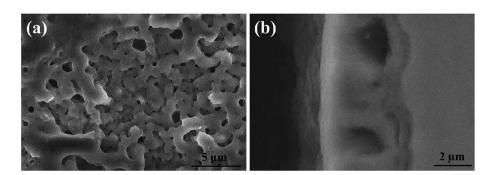


Fig. 4 SEM morphologies of pure TiO<sub>2</sub> film after MAO treatment: (a) surface, (b) cross-section.

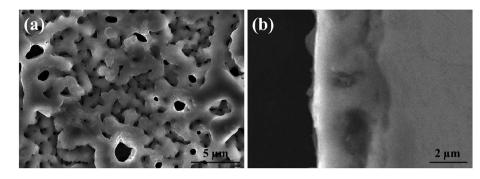


Fig. 5 SEM morphologies of the  $TiO_{2-x}C_x$  film after MAO treatment: (a) surface, (b) cross-section.

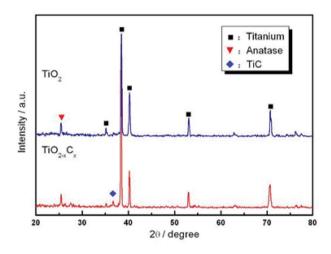


Fig. 6 XRD patterns of pure TiO<sub>2</sub> film and TiO<sub>2-x</sub>C<sub>x</sub> film after MAO treatment.

be calculated as 6.07 at%. Then, x = 0.24 could be calculated from the generic formula of  $\text{TiO}_{2-x}C_x$ . Compared with the other methods, the present two-step process provided a possibility for both substitutional carbon-doping and high doping content. Table 2 lists the carbon doping data for various methods.

Fig. 8 illustrates the DRS profiles of pure  $TiO_2$  and the  $TiO_{2-x}C_x$  film. Obviously, the  $TiO_{2-x}C_x$  film exhibited a red shift in the band gap transition and remarkably expanded

wavelength response range to visible light; *i.e.*, the absorption edge of  $\text{TiO}_{2-x}C_x$  film was shifted from the wavelength of 400 nm to 410 nm and exhibited a higher absorption. Using the Kubelka–Munk equations,<sup>28</sup> the relationship between  $(\alpha hv)^{1/2}$  and the photo energy of the films can be determined. As shown in Fig. 9, the bandwidths of pure TiO<sub>2</sub> film and TiO<sub>2-x</sub>C<sub>x</sub> film were 3.02 eV and 2.77 eV, respectively, which demonstrates that the energy band-gap of TiO<sub>2</sub> had been narrowed by C doping.

Further, we measured the content of  $\cdot$ OH to reflect the photocatalytic properties of the samples. Because TA can be combined with  $\cdot$ OH, the generated TAOH has a strong fluorescence emission peak at 426 nm, so it is used as a reagent for fluorescence detection. Fig. 10 shows the fluorescence intensity of TA solutions containing pure TiO<sub>2</sub> film and TiO<sub>2-x</sub>C<sub>x</sub> film at different illumination times. The experimental results indicated that the content of  $\cdot$ OH from the TiO<sub>2-x</sub>C<sub>x</sub> film was about two times more than that of pure TiO<sub>2</sub> film, and it exhibited a high photocatalytic performance.

In general, there are two kinds of strategies to prepare the Cdoped TiO<sub>2</sub>, *i.e.*, incorporating carbon atoms into the TiO<sub>2</sub> lattice ( $C \rightarrow TiO_2$ ) and oxidizing the titanium carbide ( $O \rightarrow TiC_x$ ). However, for preparation of the substitutional C-doped TiO<sub>2</sub>, the most used methods include direct thermal oxidation of TiC powders, pulsed laser deposition, chemical-vapor deposition, hydrothermal method, and annealing. Direct thermal oxidation of TiC powder is a simple one-step process, but the C doping concentration is low, and it is difficult to be recycled and can

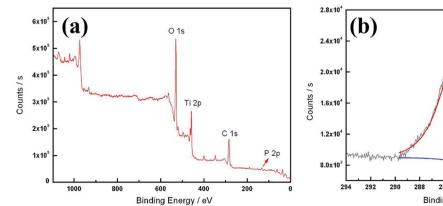


Fig. 7 XPS spectra of the  $TiO_{2-x}C_x$  film: (a) survey, (b) C 1s peaks.

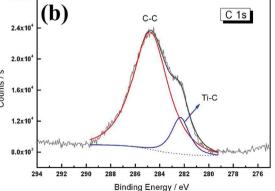


Table 2	Carbon content of the substit	utional carbon-doped	TiO <sub>2</sub> produced by	various methods
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Catalyst	Method	Carbon content	Ref.
Carbon-doped TiO <sub>2</sub> powders	Thermal oxidation	0.32%	12
TiO <sub>2</sub> -C1a/TiO <sub>2</sub> -C1b/TiO <sub>2</sub> -C2	Hydrolysis and calcination	2.98/0.42/0.03%	25
C–TiO <sub>2</sub> film	Pulsed laser deposition	0.3%	26
C-TiO <sub>2</sub> /C-TiO <sub>2</sub> -200	Hydrothermal and annealing	0.19/0.28 at%	15
CT-BE/CE-BE-265	Calcination assisted solvothermal	0.6/0.42 at%	16
TiO <sub>2</sub> -1/TiO <sub>2</sub> -2/TiO <sub>2</sub> -3	CVD, hydrothermal, and annealing	2.3/2.8/3.9%	27
Carbon-doped TiO <sub>2</sub> film	Gas carburizing and MAO	6.07 at%	Our work

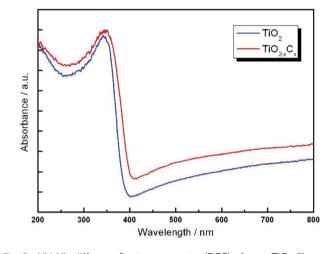


Fig. 8 UV-Vis diffuse reflectance spectra (DRS) of pure TiO<sub>2</sub> film and TiO<sub>2-x</sub>C<sub>x</sub> film.

easily cause secondary pollution during photocatalytic degradation. Pulsed laser deposition and chemical-vapor deposition can also be a one-step process for producing the C-doped TiO<sub>2</sub>, but they usually require high energy under more stringent experimental conditions. Hydrothermal reaction and annealing are undoubtedly the most commonly used two-step method to prepare C-doped TiO<sub>2</sub>. However, some special reagents used in hydrothermal processes may pollute the environment, and the problem of low C concentration still exists.

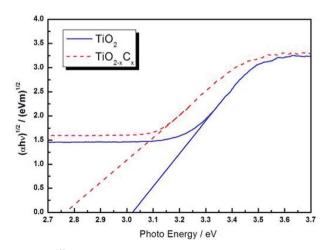


Fig. 9  $(\alpha h v)^{1/2}$  profiles as a function of photo energy for pure TiO<sub>2</sub> film and TiO<sub>2-x</sub>C<sub>x</sub> film.

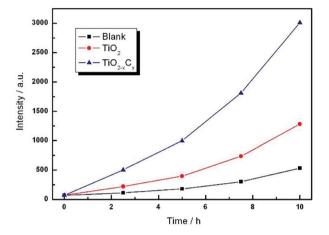


Fig. 10 Time dependences of fluorescence intensity generated by pure  $TiO_2$  film and the  $TiO_{2-x}C_x$  film on continuous illumination.

For the present work, although the experiment is a two-step process, both gas carburizing and MAO are commonly used techniques in industry for surface modification of workpieces. Significantly, it can produce the substitutional C-doped  $TiO_2$ film with high concentration. Thus, it possesses the advantages of being simple, economical, and efficient, and the processes of gas carburizing and MAO causes no environmental problems. In addition, it adapts to mass production for the preparation of high-concentration substitutional C-doped  $TiO_2$  film, particularly with a large surface area.

#### 4. Conclusions

A high-concentration substitutional carbon-doped  $\text{TiO}_2$  ( $\text{TiO}_{2-x}C_x$ ) film is prepared *via* a novel two-step process, *i.e.*, combining gas carburizing thermochemical treatment and MAO techniques. The concentration of the Ti–C band reaches 6.07 at%, and the carbon doping amount is as high as x = 0.24. Therefore, the TiO<sub>2-x</sub>C<sub>x</sub> film exhibits a significant red-shift in the band-gap transition, a narrow band gap of 2.77 eV, and excellent photocatalytic performance. This method is simple, efficient, economical, environmentally friendly, and adapts to mass production. According to this principle, doping with other materials, such as metal element doping, nonmetal element doping, metal and non-metal element co-doping, *etc.*, can be performed in the future.

# Conflicts of interest

There are no conflicts to declare.

## Acknowledgements

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